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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO	
09 720,609	12-26, 2000	Masaki Aoki	NAK1-BN46	2430	
75	90 06 04 2003				
Joseph W Price Price Gress & Ubell 2100 SE Main St Suite 250			EXAMINER		
			YUN, JURIE		
Irvine, CA 926	-14		ART UNIT	PAPER NUMBER	
			2882		

DATE MAILED: 06/04/2003

Please find below and/or attached an Office communication concerning this application or proceeding.

		Applicati	on No.	Applicant(s)	li
•		09/720,6	09	AOKI ET AL.	W
•	Office Action Summary	Examine	r	Art Unit	
	_	Jurie Yu	า	2882	
	The MAILING DATE of this commun	nication appears on th	e cover s	heet with the correspondence ac	ddress
Period for	• •				
THE M - Extens after S - If the p - If NO p - Failure - Any re	RATENED STATUTORY PERIOD F IAILING DATE OF THIS COMMUN sions of time may be available under the provisions IX (6) MONTHS from the mailing date of this community of the provisions of time may be pecified above is less than thirty (5) period for reply is specified above, the maximum is a to reply within the set or extended period for reply ply received by the Office later than three months in patent term adjustment. See 37 CFR 1 704(b).	ICATION. s of 37 CFR 1.136(a). In no exmunication 30) days, a reply within the sta tatutory period will apply and v y will, by statute, cause the app	rent, however tutory minimu rill expire SIX blication to be	may a reply be timely filed im of thirty (30) days will be considered time (6) MONTHS from the mailing date of this occome ABANDONED (35 U S C. § 133)	
1) <u>\</u>	Responsive to communication(s) fi	ilad on 26 Dagambar	2000		
لڪارا [2a]				ı	
/ 		2b)⊠ This action is			· · · · · · · · · · · · · · · · · ·
3) <u> </u>	Since this application is in condition closed in accordance with the practor of Claims				ne merits is
4)[2] (Claim(s) <u>2-10 and 18-27</u> is/are pen	ding in the application	٦.		
4	a) Of the above claim(s) is/a	are withdrawn from co	nsiderati	on.	
5) 🖸 (Claim(s) <u>18,19,21,26 and 27</u> is/are	allowed.			
	Claim(s) <u>2,5,6,9,20 and 22-25</u> is/are				
<u> </u>	Claim(s) <u>3,4,7,8 and 10</u> is/are object				
8) 🔲 (Claim(s) are subject to restric	ction and/or election r	equireme	ent.	
	n Papers				
9) ⊠ T	he specification is objected to by th	e Examiner.			
10)[T	he drawing(s) filed on is/are:	a) accepted or b)	objected	to by the Examiner.	
	Applicant may not request that any ob-	jection to the drawing(s	be held i	n abeyance. See 37 CFR 1.85(a).	
11) 🔲 T	he proposed drawing correction file	d on is: a) ☐ a	pproved	b) \square disapproved by the Examin	ier.
	If approved, corrected drawings are re	· -	ffice action	1.	
12) 🔲 T	he oath or declaration is objected to	b by the Examiner.			
riority ur	nder 35 U.S.C. §§ 119 and 120				
13) I	Acknowledgment is made of a claim	n for foreign priority ur	nder 35 U	.S.C. § 119(a)-(d) or (f).	
a)∑	All b) Some * c) None of:				
•	Certified copies of the priority	documents have bee	n receive	ed.	
2	2. Certified copies of the priority	documents have bee	n receive	ed in Application No	
	B. Copies of the certified copies application from the Interret the attached detailed Office actions.	national Bureau (PCT	Rule 17.	2(a)).	Stage
14) 🗌 Ad	knowledgment is made of a claim f	or domestic priority u	nder 35 L	J.S.C. § 119(e) (to a provisiona	l application).
	☐ The translation of the foreign lar		•		
ttachment(5)				
2) D Notice	of References Cited (PTO-892) of Draftsperson's Patent Drawing Review (F ation Disclosure Statement(s) (PTO-1449) P		5) 🔲 No	erview Summary (PTO-413) Paper No stice of Informal Patent Application (PT her:	
Patent and Trac	demark Office 04-01)	Office Action Summa	D/	Part of Paper No. 5	

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DETAILED ACTION

Specification

- 1. The abstract of the disclosure is objected to because it contains more than 150 words. Correction is required. See MPEP § 608.01(b).
- 2. Claims 2-9 and 18-19 are objected to because of the following informalities: "Plasm" should be "Plasma". Appropriate correction is required.
- 3. Claims 20-27 are objected to because of the following informalities: It is unclear what is meant by the "loss factor tan" of the dielectric layer. One of ordinary skill in the art would not know how to calculate the loss factor tan of a material. Appropriate correction is required.

Claim Rejections - 35 USC § 103

- 4. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 5. Claims 2, 5, 6, 9, 20, and 22-25 are rejected under 35 U.S.C. 103(a) as being unpatentable over Shoji (JP 09-278482).
- 6. With respect to claim 20, Shoji discloses (Detailed Description, paragraph 4) a plasma display panel in which a space between a first plate and a second plate facing each other is filled with a discharge gas, a plurality of pairs of display electrodes made of Ag are formed on a surface of the first plate facing the second plate, and the surface of the first plate is covered with a dielectric layer covering the plurality of pairs of display

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electrodes. Shoji is silent as to the material of the display electrodes, but one of ordinary skill in the art would know that the use of Ag for display electrodes is well known. Shoji also discloses (Table 1, sample 1) the dielectric layer is made of a glass that contains at least ZnO and 10 wt% or less of R₂O and does not substantially contain PbO and Bi₂O₃, wherein R is selected from a group consisting of Li, Na, K, Rb, Cs, Cu, and Ag.

Shoji does not disclose a product of permittivity and loss factor tan of the dielectric layer is 0.12 or less. However, since the same materials are disclosed, one of ordinary skill in the art would assume this to be the case. It would have been obvious to one of ordinary skill in the art at the time the invention was made to modify the Shoji invention and disclose a product of permittivity and loss factor tan of the dielectric layer is 0.12 or less. Shoji is concerned with (Problems to be Solved by the Invention, paragraph 8) lowering the dielectric constant (a.k.a. permittivity), which in turn would result in a lower product of permittivity and loss factor tan of the dielectric layer. This equates to lower power consumption, which is another objective.

- 7. With respect to claim 2, Shoji discloses the permittivity of the dielectric layer is 7 or less (Problems to be Solved by the Invention, paragraph 11).
- 8. With respect to claim 5, Shoji discloses (Table 1, sample 5) the dielectric layer is composed of a ZnO-base glass which contains 20-44 wt% of ZnO, 38-55 wt% of B_2O_3 , 5-12 wt% of SiO_2 , 10 wt% or less of R_2O , and 10 wt% or less of MO, and the permittivity of the dielectric layer is 7 or less, wherein R is selected from a group consisting of Li,

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Na, K, Rb, Cs, Cu, and Ag, and M is selected from a group consisting of Mg, Ca, Ba, Sr, Co, and Cr.

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- 9. With respect to claim 6, Shoji discloses (Table 1, sample 5) the dielectric layer is composed of a ZnO-base glass which contains 20-43 wt% of ZnO, 38-55 wt% of B₂O₃, 5-12 wt% of SiO₂, 1-10 wt% of Al₂O₃, 10 wt% or less of R₂O, and 10 wt% or less of MO, and the permittivity of the dielectric layer is 7 or less, wherein R is selected from a group consisting of Li, Na, K, Rb, Cs, Cu, and Ag, and M is selected from a group consisting of Mg, Ca, Ba, Sr, Co, and Cr.
- 10. With respect to claim 9, Shoji discloses (Table 1, sample 2) the dielectric layer is composed of a ZnO-base glass which contains 35-60 wt% of ZnO, 25-45 wt% of B_2O_3 , 1-12 wt% of SiO₂, 1-10 wt% of Al₂O₃, and 5 wt% or less of K_2O , and the permittivity of the dielectric layer is 7 or less.
- 11. With respect to claim 22, Shoji discloses (Detailed Description, paragraph 4) a plasma display panel in which a space between a first plate and a second plate facing each other is filled with a discharge gas, a plurality of pairs of display electrodes made of Ag are formed on a surface of the first plate facing the second plate, and the surface of the first plate is covered with a dielectric layer covering the plurality of pairs of display electrodes. Shoji is silent as to the material of the display electrodes, but one of ordinary skill in the art would know that the use of Ag for display electrodes is well known. Shoji also discloses (Table 1, sample 1) the dielectric layer is made of a glass which is composed of 30-45 wt% of ZnO, 40-60 wt% of B₂O₃, and 1-15 wt% of SiO₂.

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Shoji does not disclose a product of permittivity and loss factor tan of the dielectric layer is 0.12 or less. However, since the same materials are disclosed, one of ordinary skill in the art would assume this to be the case. It would have been obvious to one of ordinary skill in the art at the time the invention was made to modify the Shoji invention and disclose a product of permittivity and loss factor tan of the dielectric layer is 0.12 or less. Shoji is concerned with (Problems to be Solved by the Invention, paragraph 8) lowering the dielectric constant (a.k.a. permittivity), which in turn would result in a lower product of permittivity and loss factor tan of the dielectric layer. This equates to lower power consumption, which is another objective.

12. With respect to claim 23, Shoji discloses (Detailed Description, paragraph 4) a plasma display panel in which a space between a first plate and a second plate facing each other is filled with a discharge gas, a plurality of pairs of display electrodes made of Ag are formed on a surface of the first plate facing the second plate, and the surface of the first plate is covered with a dielectric layer covering the plurality of pairs of display electrodes. Shoji is silent as to the material of the display electrodes, but one of ordinary skill in the art would know that the use of Ag for display electrodes is well known. Shoji also discloses (Table 1, sample 8) the dielectric layer is made of a glass which is composed of 30-45 wt% of ZnO, 40-55 wt% of B₂O₃, 1-10 wt% of SiO₂, 1-10 wt% of Al₂O₃, and 1-5 wt% of CaO.

Shoji does not disclose a product of permittivity and loss factor tan of the dielectric layer is 0.12 or less. However, since the same materials are disclosed, one of ordinary skill in the art would assume this to be the case. It would have been obvious to

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one of ordinary skill in the art at the time the invention was made to modify the Shoji invention and disclose a product of permittivity and loss factor tan of the dielectric layer is 0.12 or less. Shoji is concerned with (Problems to be Solved by the Invention, paragraph 8) lowering the dielectric constant (a.k.a. permittivity), which in turn would result in a lower product of permittivity and loss factor tan of the dielectric layer. This equates to lower power consumption, which is another objective.

13. With respect to claim 24, Shoji discloses (Detailed Description, paragraph 4) a plasma display panel in which a space between a first plate and a second plate facing each other is filled with a discharge gas, a plurality of pairs of display electrodes made of Ag are formed on a surface of the first plate facing the second plate, and the surface of the first plate is covered with a dielectric layer covering the plurality of pairs of display electrodes. Shoji is silent as to the material of the display electrodes, but one of ordinary skill in the art would know that the use of Ag for display electrodes is well known. Shoji also discloses (Table 1, sample 2) the dielectric layer is made of a glass which is composed of 40-60 wt% of ZnO, 35-45 wt% of B₂O₃, 1-10 wt% of SiO₂, and 1-10 wt% of Al₂O₃.

Shoji does not disclose a product of permittivity and loss factor tan of the dielectric layer is 0.12 or less. However, since the same materials are disclosed, one of ordinary skill in the art would assume this to be the case. It would have been obvious to one of ordinary skill in the art at the time the invention was made to modify the Shoji invention and disclose a product of permittivity and loss factor tan of the dielectric layer is 0.12 or less. Shoji is concerned with (Problems to be Solved by the Invention,

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paragraph 8) lowering the dielectric constant (a.k.a. permittivity), which in turn would result in a lower product of permittivity and loss factor tan of the dielectric layer. This equates to lower power consumption, which is another objective.

14. With respect to claim 25, Shoji discloses (Detailed Description, paragraph 4) a plasma display panel in which a space between a first plate and a second plate facing each other is filled with a discharge gas, a plurality of pairs of display electrodes made of Ag are formed on a surface of the first plate facing the second plate, and the surface of the first plate is covered with a dielectric layer covering the plurality of pairs of display electrodes. Shoji is silent as to the material of the display electrodes, but one of ordinary skill in the art would know that the use of Ag for display electrodes is well known. Shoji also discloses (Table 1, sample 2) the dielectric layer is made of a glass which is composed of 30-60 wt% of ZnO, 30-50 wt% of B₂O₃, 1-10 wt% of SiO₂, and 1-10 wt% of Al₂O₃.

Shoji does not disclose a product of permittivity and loss factor tan of the dielectric layer is 0.12 or less. However, since the same materials are disclosed, one of ordinary skill in the art would assume this to be the case. It would have been obvious to one of ordinary skill in the art at the time the invention was made to modify the Shoji invention and disclose a product of permittivity and loss factor tan of the dielectric layer is 0.12 or less. Shoji is concerned with (Problems to be Solved by the Invention, paragraph 8) lowering the dielectric constant (a.k.a. permittivity), which in turn would result in a lower product of permittivity and loss factor tan of the dielectric layer. This equates to lower power consumption, which is another objective.

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Allowable Subject Matter

- 15. Claims 3, 4, 7, 8, and 10 are objected to as being dependent upon a rejected base claim, but would be allowable if rewritten in independent form including all of the limitations of the base claim and any intervening claims. The following is a statement of reasons for the indication of allowable subject matter: Prior art fails to disclose the dielectric layer contains 10-25 wt% of P₂O₅, 20-35 wt% of ZnO, 30-40 wt% of B₂O₃, 5-12 wt% of SiO₂, 10 wt% or less of R₂O, and 10 wt% or less of DO, wherein D is selected from a group consisting of Mg, Ca, Ba, Sr, Co, Cr, and Ni. Prior art also fails to disclose the dielectric layer is composed of a ZnO-P₂O₅ -base glass which contains 42-50 wt% of P₂O₅, 35-50 wt% of ZnO, 7-14 wt% of Al₂O₃, and 5 wt% or less of Na₂O. Prior art also fails to disclose the dielectric layer is composed of a ZnO-base glass which contains 1-15 wt% of ZnO, 20-40 wt% of B₂O₃, 10-30 wt% of SiO₂, 5-25 wt% of Al₂O₃, 3-10 wt% of Li₂O, and 2-15 wt% of MO, wherein M is selected from a group consisting of Mg, Ca, Ba, Sr, Co, and Cr. Prior art also fails to disclose the dielectric layer is composed of a ZnO-base glass which contains 35-60 wt% of ZnO, 25-45 wt% of B₂O₃, 1-10.5 wt% of SiO₂, 1-10 wt% of Al₂O₃, and 5 wt% or less of Na₂O. Prior art also fails to disclose the dielectric layer is composed of a ZnO-Nb₂O₅-base glass which contains 9-19 wt% of Nb₂O₅ 35-60 wt% of ZnO, 20-38 wt% of B₂O₃, 1-10.5 wt% of SiO₂, and 5 wt% or less of Li₂O.
- 16. Claims 21, 26, and 27 are allowed.
- 17. The following is an examiner's statement of reasons for allowance: Prior art fails to disclose the dielectric layer is made of a glass which is composed of 20-30 wt% of

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 P_2O_5 , 30-40 wt% of ZnO, 30-45 wt% of B_2O_3 , and 1-10 wt% of SiO₂ and a product of permittivity and loss factor tan of the dielectric layer is 0.12 or less. Prior art also fails to disclose the dielectric layer is made of a glass which is composed of 9-20 wt% of Nb_2O_5 , 35-60 wt% of ZnO, 25-40 wt% of B_2O_3 , and 1-10 wt% of SiO_2 , and a product of permittivity and loss factor tan of the dielectric layer is 0.12 or less. Prior art also fails to disclose the dielectric layer is composed of a first dielectric layer which either is a thin film of SiO_2 , Al_2O_3 or ZnO or is made of a glass containing at least PbO or Bi_2O_3 and covers the plurality of pairs of display electrodes, and a second dielectric layer made of a glass in which a product of permittivity and loss factor tan is 0.12 or less, the second dielectric layer covering the first dielectric layer.

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Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Conclusion

- 18. The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. Lee et al. (USPN 6,184,163 B1), Braude (USPN 4,578,619), Komaki (USPN 5,703,437), Tanaka et al. (USPN 6,160,345), and Aoki et al. (USPN 6,439,943 B1) disclose dielectric compositions.
- 19. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Jurie Yun whose telephone number is 703 308-3535. The examiner can normally be reached on Monday-Friday 8:30-5:00pm.

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If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Robert H. Kim can be reached on 703 305-3492. The fax phone numbers for the organization where this application or proceeding is assigned are 703 308-7722 for regular communications and 703 308-7722 for After Final communications.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is 703 308-0956.

Jurie Yun May 27, 2003



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